

The Future of Deep Submicron IC Design for HEP

Ray Yarema

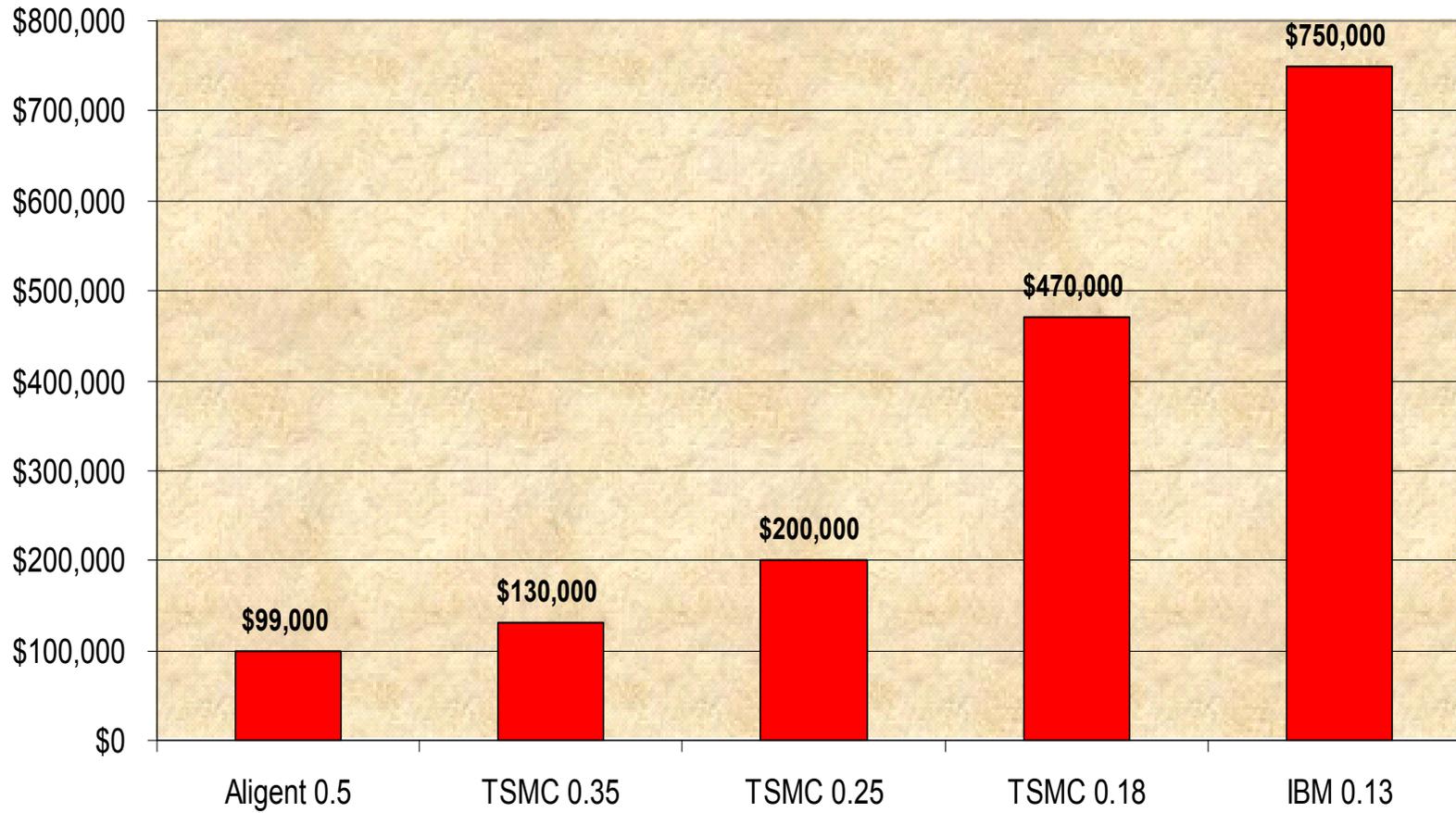
Fermilab



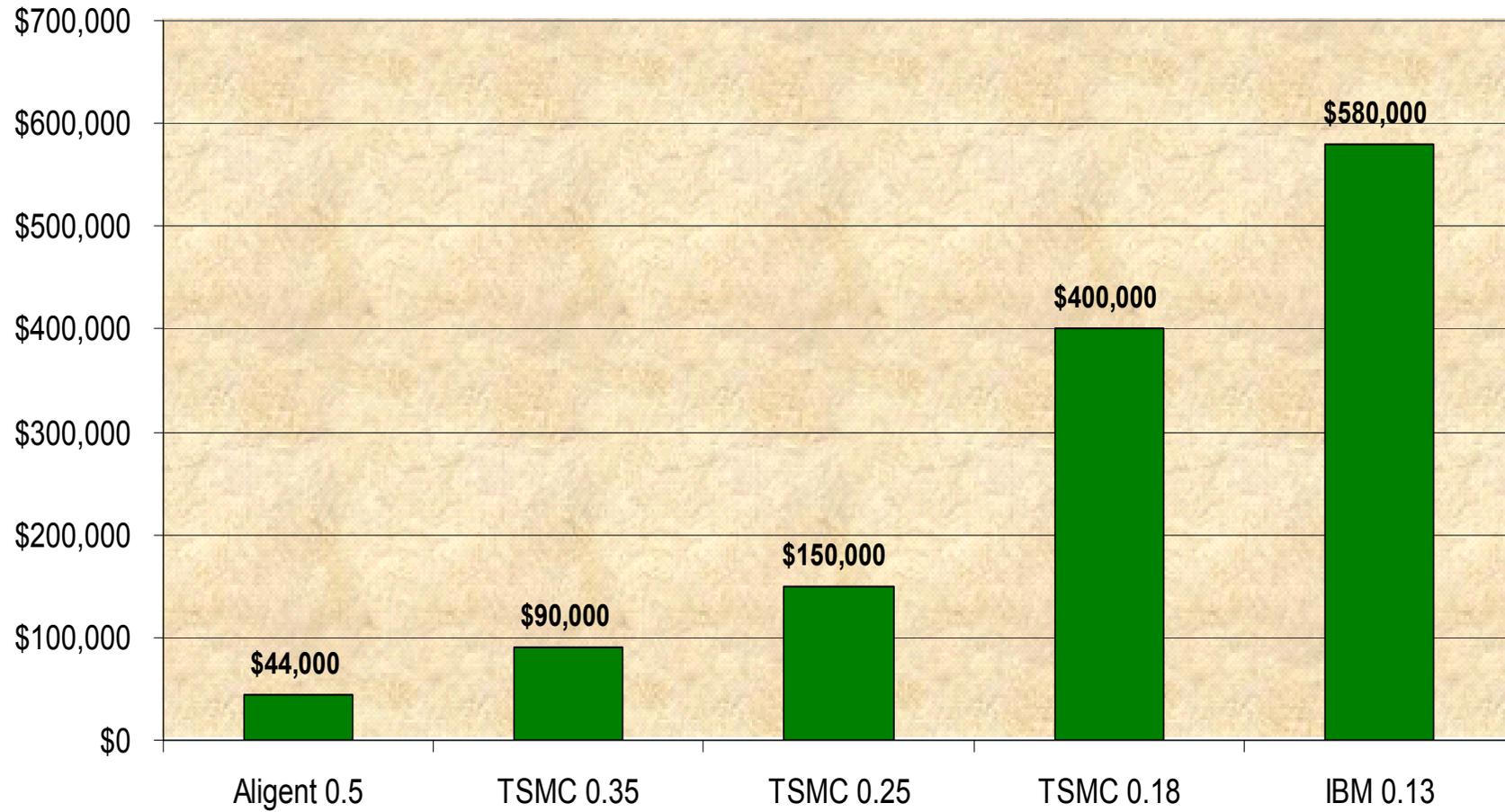
Future DSM costs

- Compare fabrication costs from one source (MOSIS)
 - Engineering runs
 - Masks
 - Silicon area
- Fabrication cost could be lower (30%??) if special arrangements are made.
- Other engineering costs may still be dominant factor

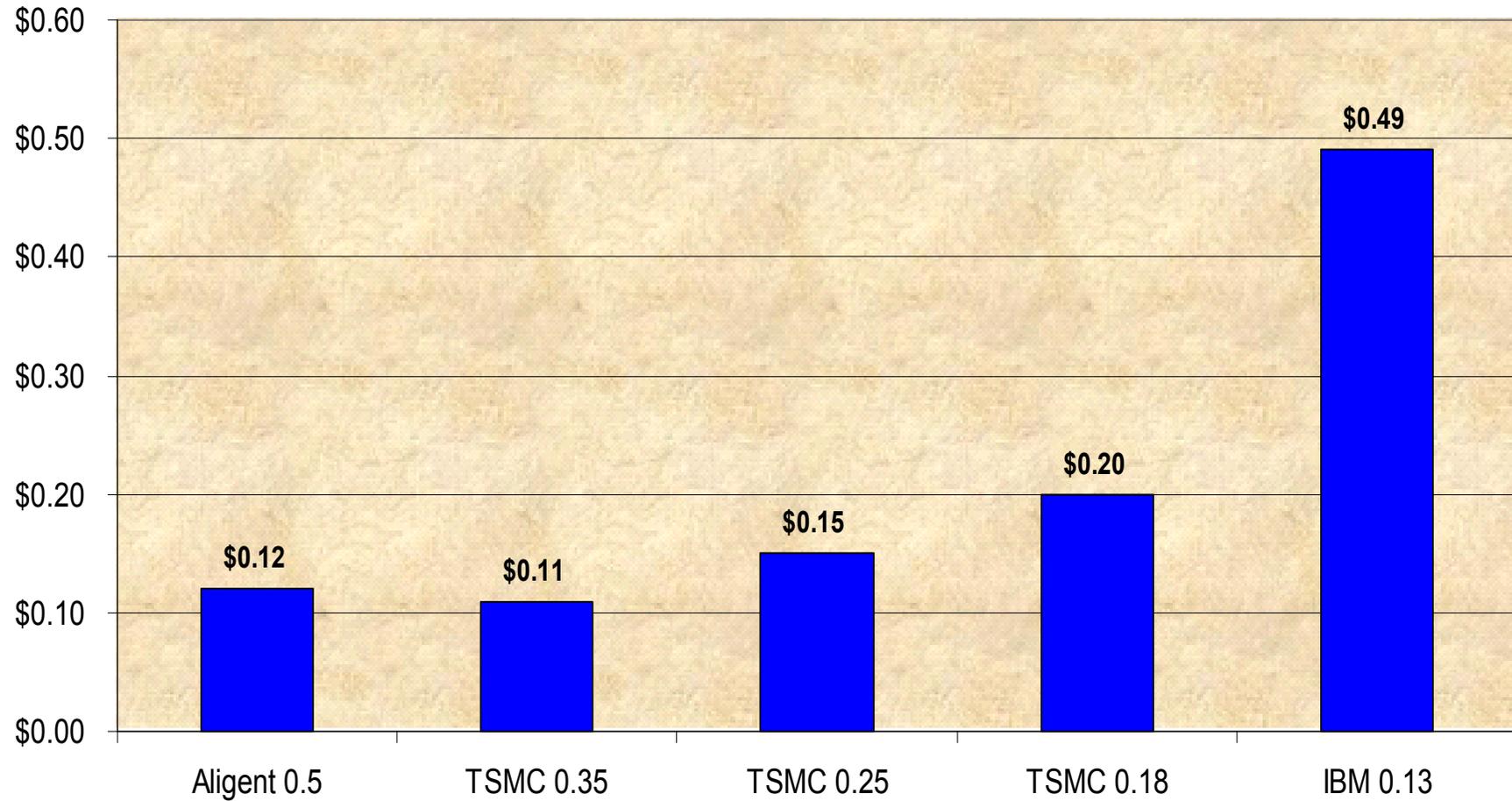
MOSIS Engineering Run Cost



Mask Costs for Engineering Runs at MOSIS



Engineering Run Wafer Cost/mm2



Future Projects

- Future projects will not be on a scale as large as LHC
 - Next Linear Collider
 - LHC upgrades
 - Astrophysics projects
 - Phenix, BTeV, Off-axis neutrinos, etc.
- Makes private MPW runs more difficult for cost and schedule purposes

Must make some hard decisions

- May be difficult to find frequent, low cost prototyping option. Look at a new way of doing business.
- More than ever
 - it is important to share design information.
 - to save money

Foundry Direct

- **Advantages**
 - **Direct access to foundry personnel**
 - **Perhaps lower cost??**
- **Disadvantages**
 - **Foundry may be less interested than before due to low volume and extended schedule**
 - **Less frequent MPW runs**
 - **Potentially higher cost due to fewer customers if more more frequent runs are desired**
 - **Must negotiate involved contracts for export etc.**
 - **Must use in house personnel to frame projects**
 - **Must do all acceptance characterization in house.**

Commercial Broker

- Advantage
 - Frequent runs
 - Sets up export agreements
 - Characterizes wafers
- Disadvantages
 - Possible higher cost?
 - Direct access to foundry personnel may be less likely?

Compromise Proposal

- Use Regular commercial broker for MPW runs—
show MOSIS schedule
- Combine small projects to save on minimum chip
area requirement
 - 10 mm² can accommodate several test circuits – 4 x
density of 0.25 and if transistor are not enclosed even
more
 - Cost sharing example
 - Receive 40 chips
- Combine projects requiring larger quantities onto
common engineering runs to save on large cost
driver – the mask cost.

Choice of Process

- Adopt one process to be used in HEP
- Choose one commercial broker— e.g. MOSIS used
- Share design information to reduce engineering effort and time
 - Share libraries,
 - SEU tolerant cells
 - Share radiation testing results
- Need to adopt some standards for common runs
 - Use 6 or 8 levels of metal

Proposal

- Choose MOSIS as the broker
- Choose IBM as the foundry

Summary

- Use commercial broker for MPW runs
- Share 10 mm² minimum space to save money on small projects
- Plan engineering runs to share mask costs for larger quantities of parts.
- Standardize on 6 or 8 levels of metal
- Standardize on foundry (IBM?)